



Docket No.: 52352-785

*7-12-02*  
*mg*  
PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

George Jonathan KLUTH, et al.

Serial No.: 10/071,207

Group Art Unit: 2811

Filed: February 11, 2002

Examiner:

For: METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE WITH  
SUPERSATURATED SOURCE/DRAIN EXTENSIONS AND METAL SILICIDE  
CONTACTS

**TRANSMITTAL OF FORMAL DRAWINGS**

Commissioner for Patents  
Washington, DC 20231

Sir:

At the time the above application was filed, informal drawings were presented with the application.

The formal drawings are submitted herewith.

Respectfully submitted,

MCDERMOTT, WILL & EMERY

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**Date: June 7, 2002**

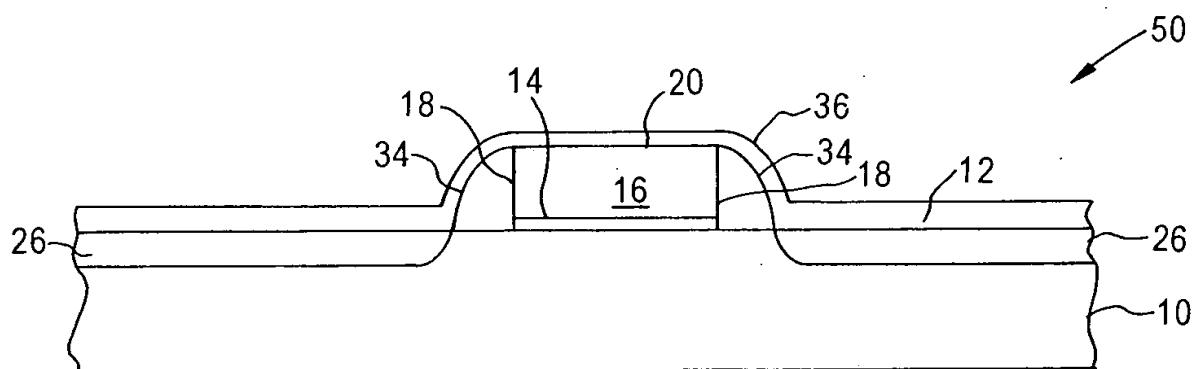


FIG. 1A  
(PRIOR ART)

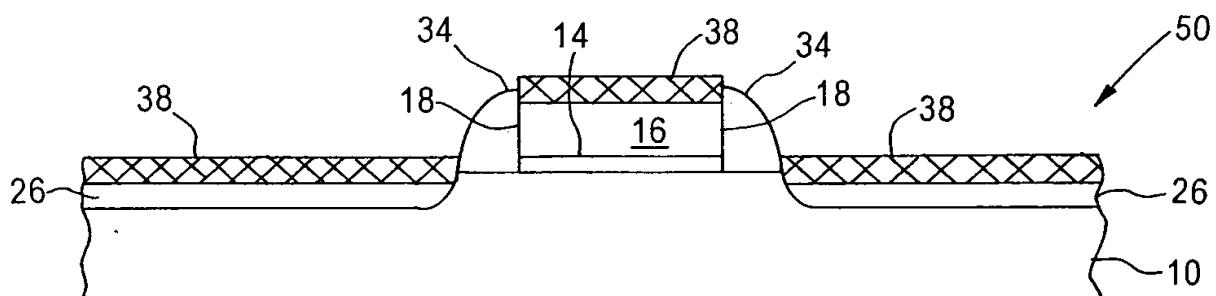


FIG. 1B  
(PRIOR ART)

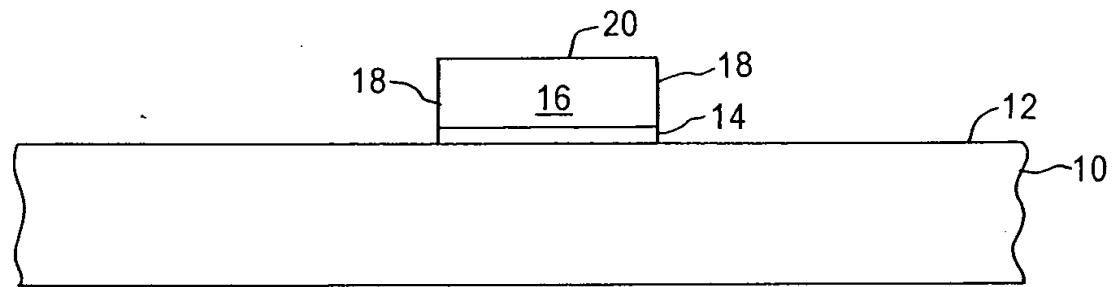


FIG. 2A

10071207-050702

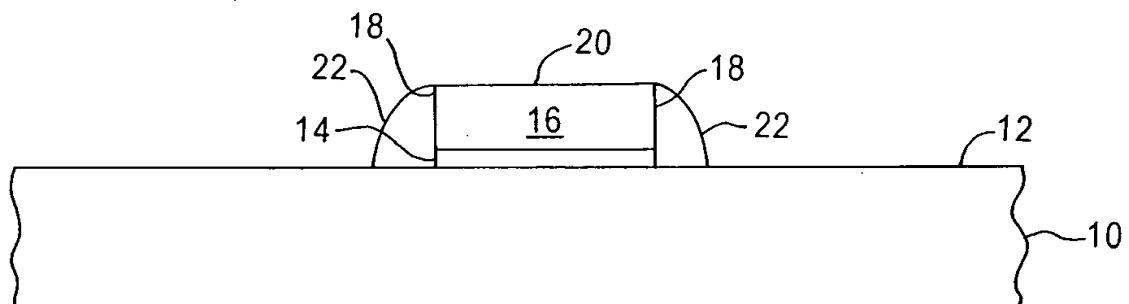


FIG. 2B

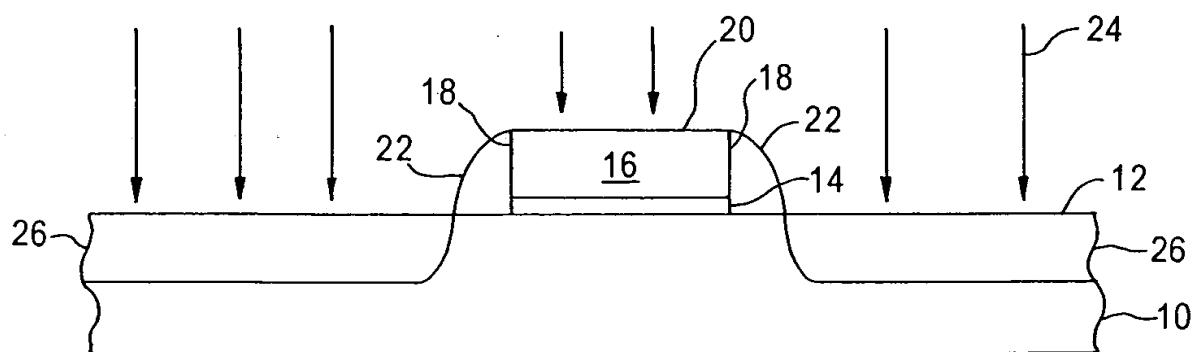
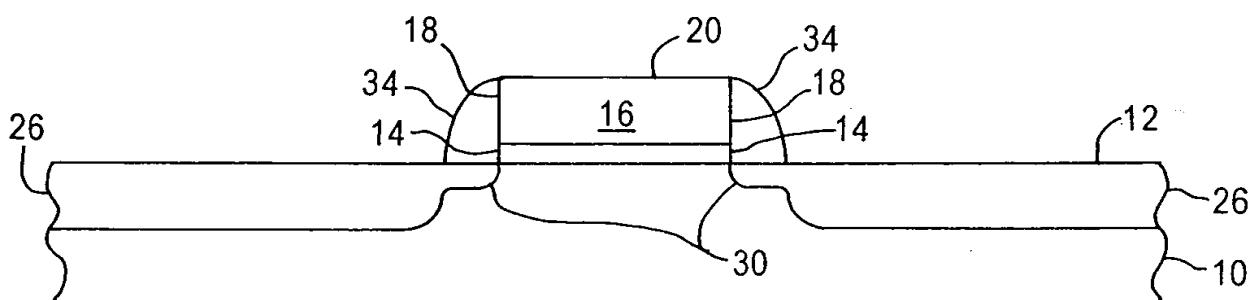
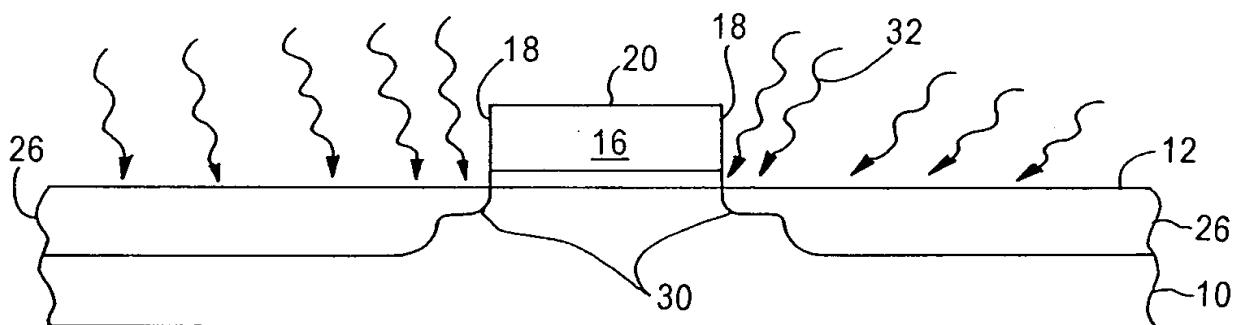
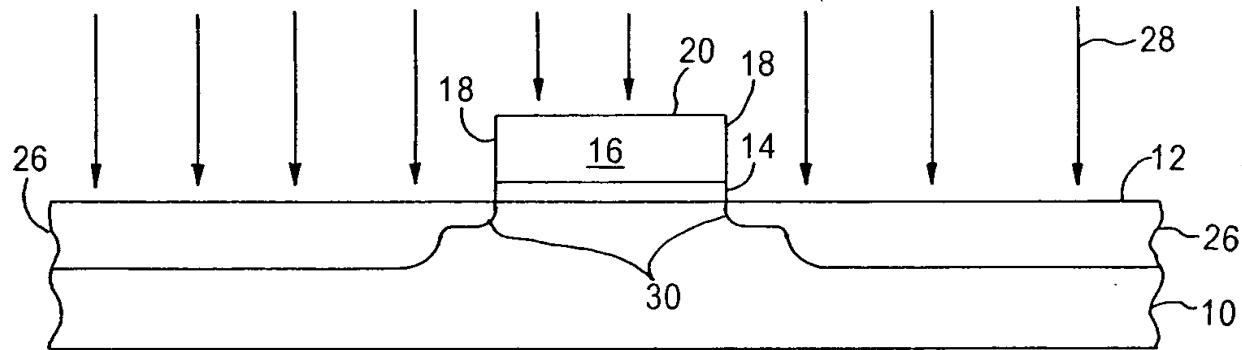


FIG. 2C



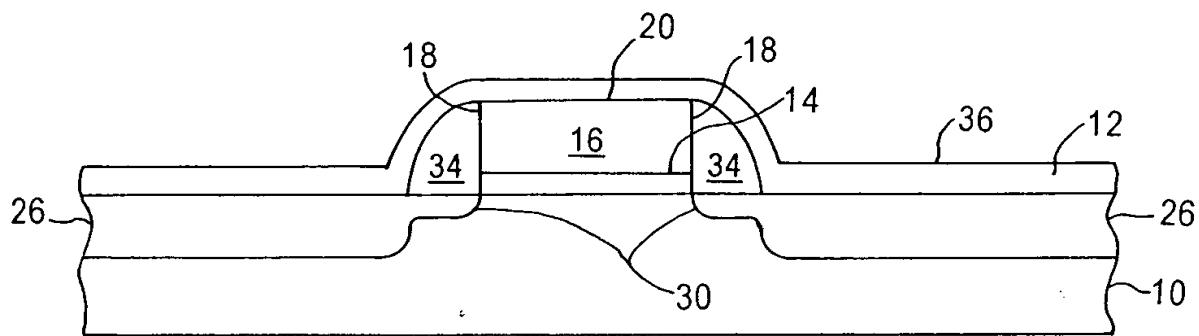


FIG. 2G

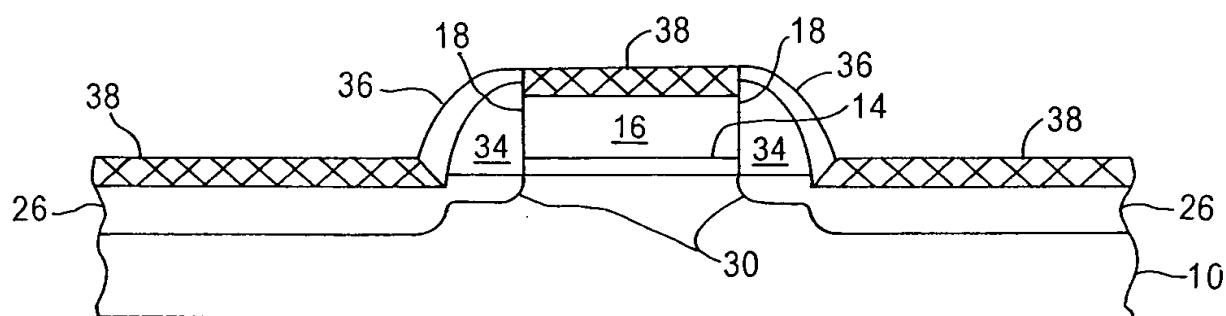


FIG. 2H

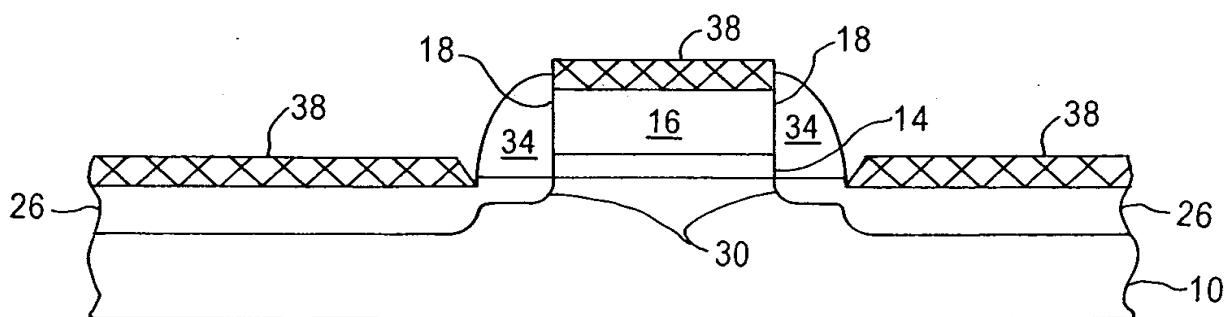


FIG. 2I

100741207-050702

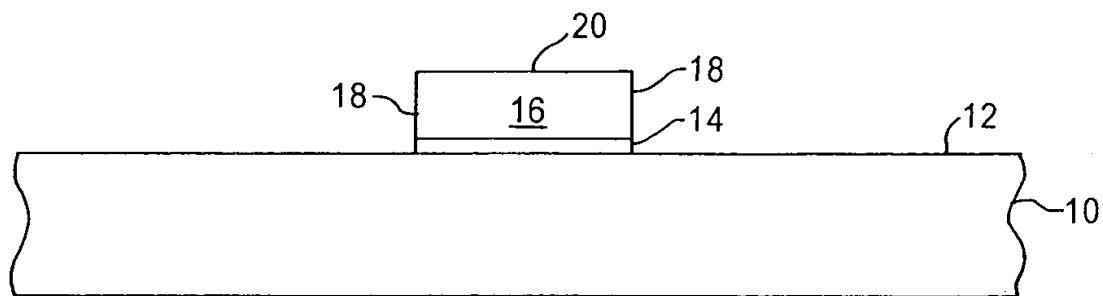


FIG. 3A

400024050-2007022

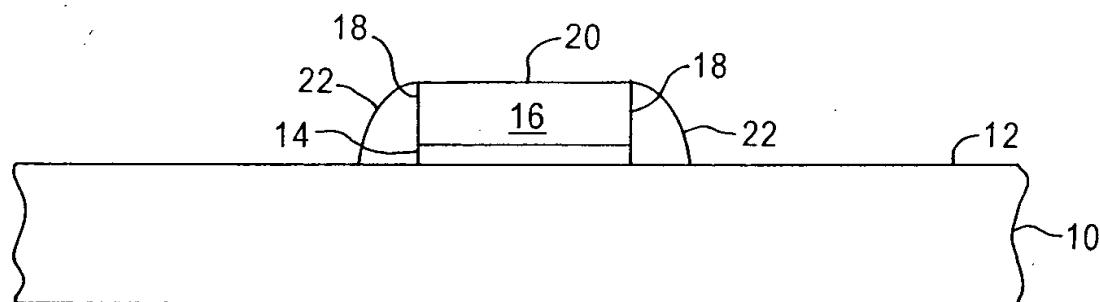


FIG. 3B

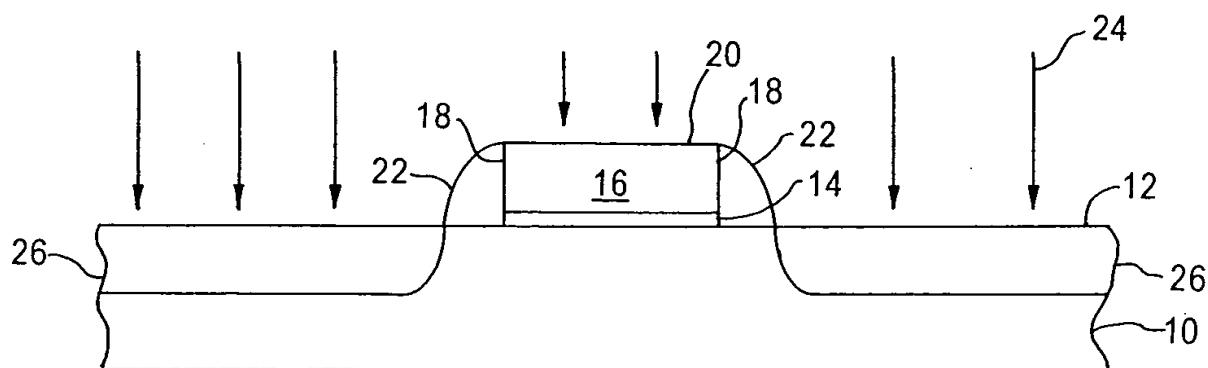


FIG. 3C

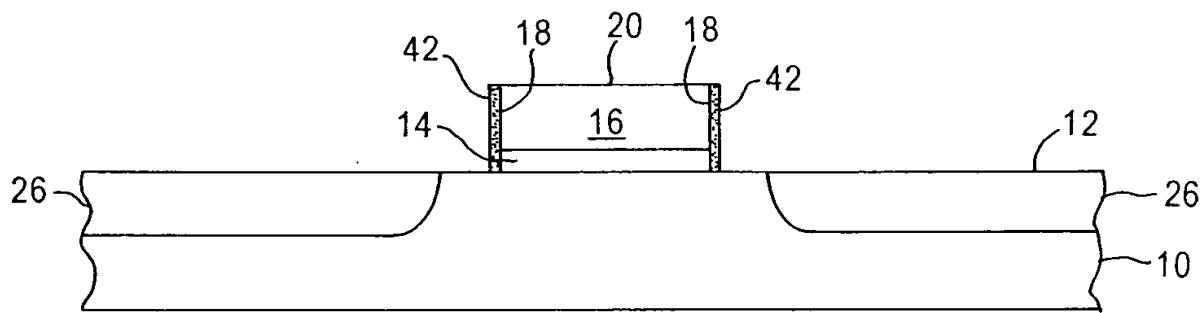


FIG. 3D

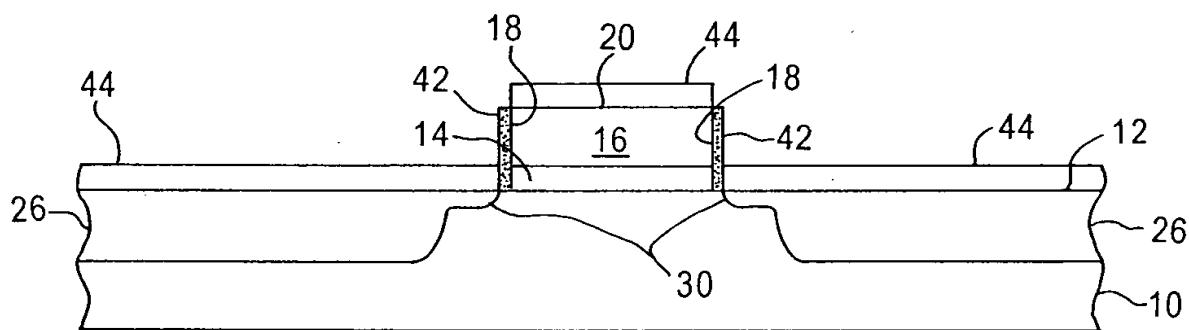


FIG. 3E

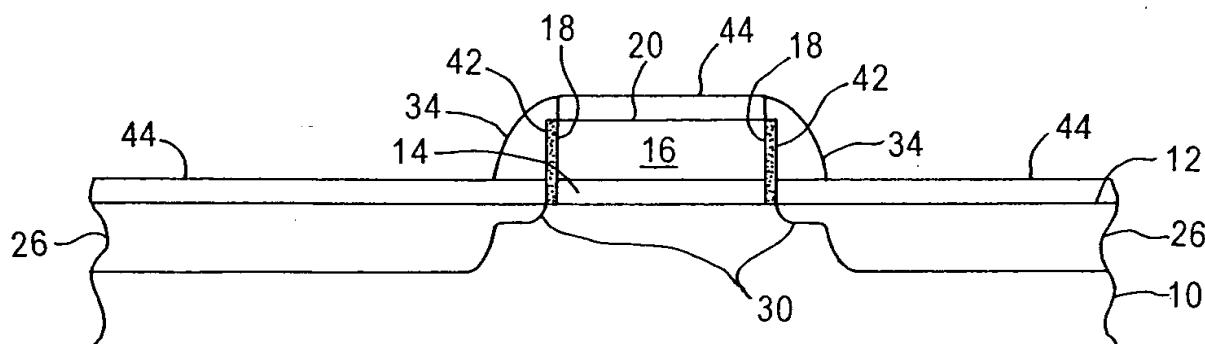


FIG. 3F

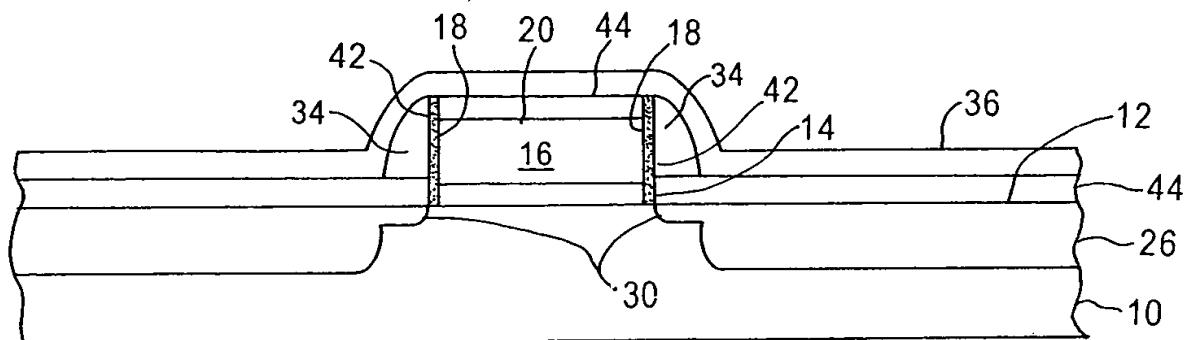


FIG. 3G

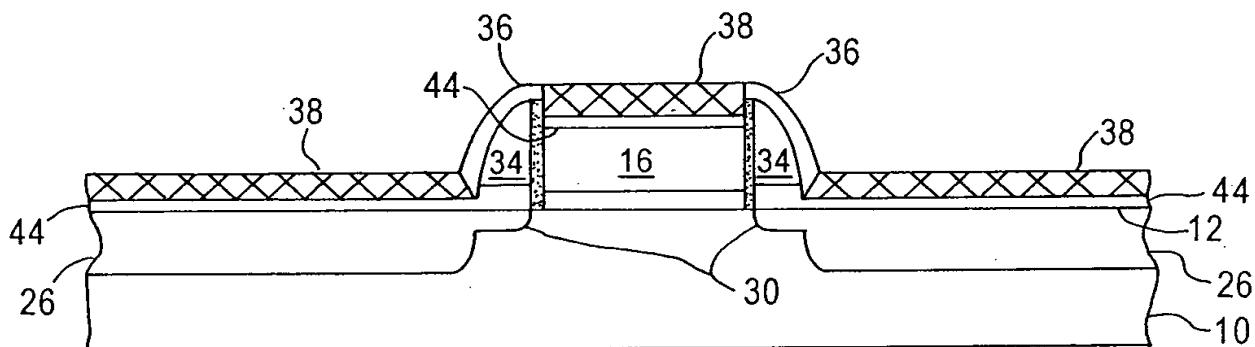


FIG. 3H

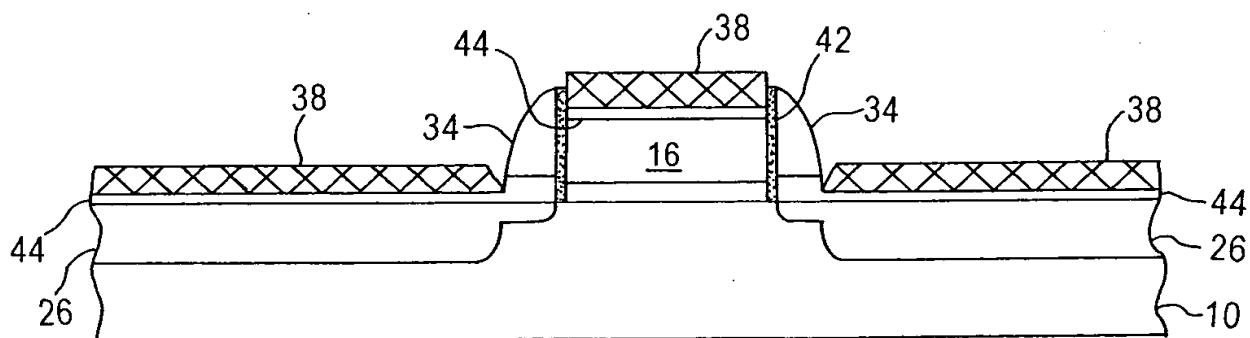


FIG. 3I

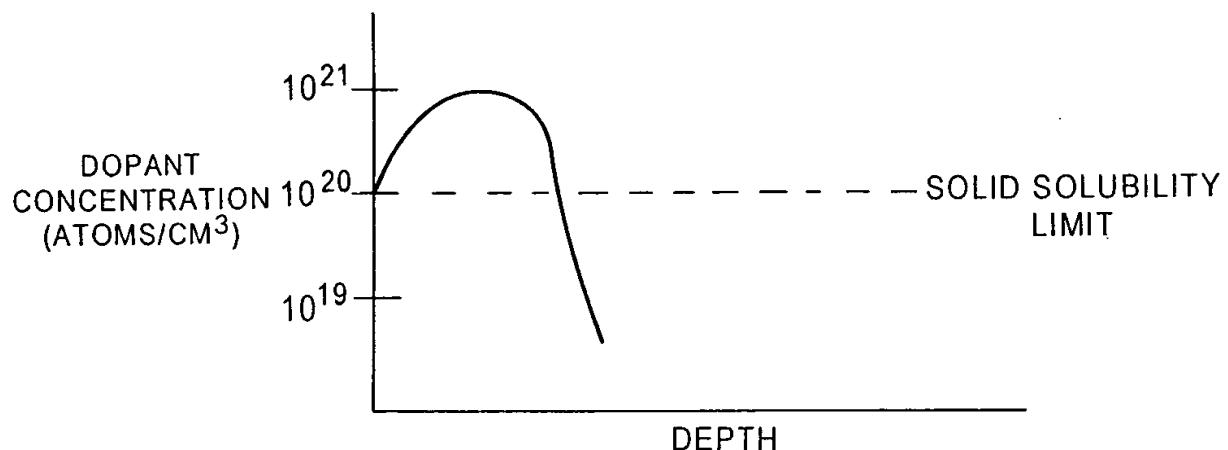


FIG. 4

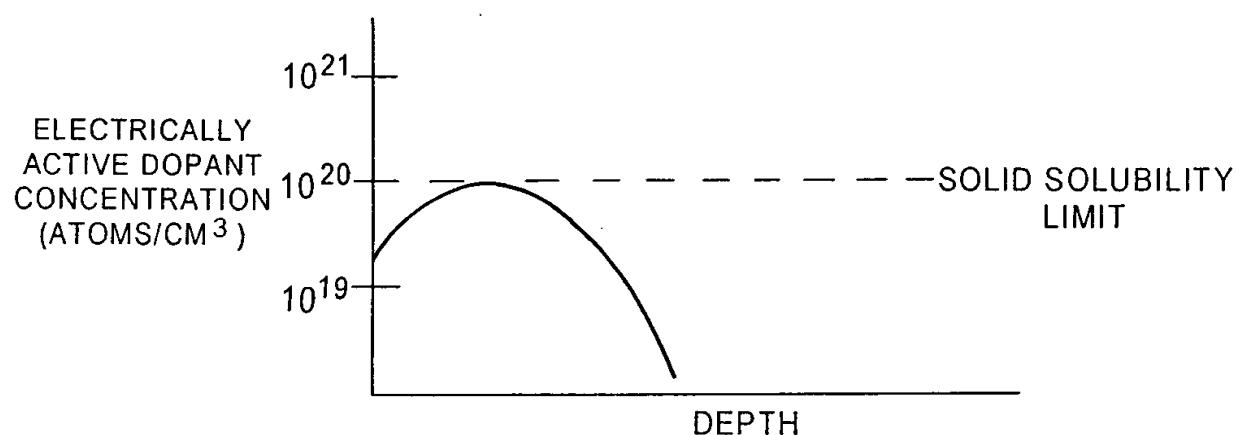


FIG. 5

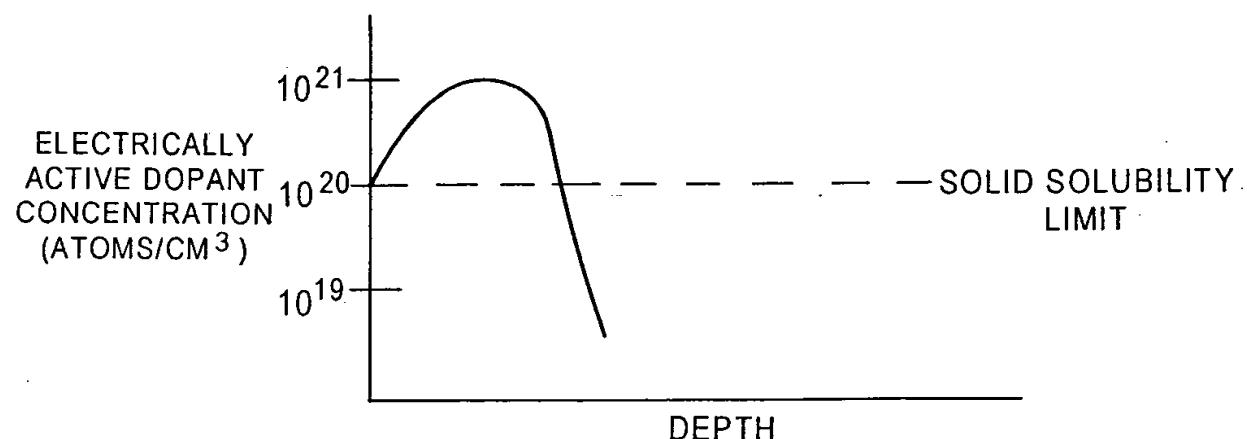


FIG. 6